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FeP₂ monolayer: isoelectronic analogue of MoS₂ with excellent electronic and optical properties†

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Two-dimensional semiconductors with suitable indirect band gaps, excellent light absorption capacity, and oxidation resistance are particularly suitable for material applications. Here based on first-principle calculations, we report that the FeP₂ monolayer, which is isoelectronic with MoS₂, has novel electronic properties and an ultra-low diffusion energy barrier of K on the surface, indicating its potential as an anode material of K-ion batteries. The calculated phonon dispersion curves, molecular dynamics, and elastic constants showed that it has high structural stability and oxidation resistance. The monolayer was a semiconductor with an indirect band gap of 0.68 eV. In addition, the FeP₂ monolayer had obvious light absorption in the infrared, visible, and ultraviolet regions, which can be widely used in optoelectronic devices. Bonding analysis showed that there were multicenter bonds inside every hexagonal ring. As the anode material of K-ion batteries, the FeP₂ monolayer had a capacity of 456.84 mA h g⁻¹, low diffusion energy barrier, and open-circuit voltage. All these characteristics suggest that the FeP₂ monolayer is a potential anode material for K-ion batteries, which needs to be further verified by experiments.

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Introduction

Since the discovery of graphene with a unique structure and physical properties in 2004,¹ an increasing number of researchers have been attracted to study two-dimensional (2D) materials.^{2–7} The calculation and prediction of new 2D materials can provide researchers with insights for synthesizing new materials, such as Cu₂Si,⁸ Ti₃C₂,⁹ and germanene,¹⁰ These materials were predicted by theoretical calculations and then synthesized through experiments. In the past decade, transition metal dichalcogenides (TMDCs) have been considered as promising 2D materials for functional devices because of their special electronic, optical, and tribological properties,^{11–14} such as MoS₂,¹⁵ MoSe₂,¹⁶ WS₂,¹⁷ and NiS₂.¹⁸ The most typical one is the MoS₂ monolayer, which has a direct band gap of 1.8 eV,¹⁹ and has excellent mechanical properties and a high charge mobility,²⁰ supporting its broad use in flexible electronic devices and as a solid lubricant in spacecraft.^{21–25} Moreover, the MoS₂ monolayer has been widely studied in the fields of photoelectron and photocatalysis due to its special crystal structure, energy band structure, high chemical stability, and

catalysis.^{26–30} Besides, two-dimensional (2D) MoS₂ has been studied theoretically and experimentally as an anode material for lithium-ion batteries (LIBs),^{31,32} sodium-ion batteries (NIBs), and potassium-ion batteries (KIBs).^{33–37} In recent years, Fe–P monolayers have attracted much attention on account of their high natural richness, low cost, good electrical conductivity, and structural stability. Zhang *et al.* predicted that the FeP₃ monolayer would exhibit excellent catalytic activity in the hydrogen evolution reaction (HER) of electrolytic water.³⁸ The Fe₃P monolayer with anisotropic high-temperature ferromagnetism is a promising candidate for spintronic nanodevices.³⁹

In the past two decades, LIBs have been widely used in electronic devices and electric vehicles due to their long cycle life and high energy density.^{40–42} However, the scarcity of Li and long charging time limit its wide-scale applications.⁴³ Therefore, we need to find cheaper and more powerful alternatives. In recent years, NIBs and KIBs have attracted more and more attention because of their rich abundance on the earth and similar chemical properties to Li.^{44–46} However, compared with NIBs, KIBs have a higher energy density and operating voltage, so it is very important to find good anode materials for KIBs.

Taking the low cost of Fe–P monolayers and the characteristics of 2D MoS₂ into account, we predict an FeP₂ monolayer, which is isoelectronic with the MoS₂ monolayer. Compared with MoS₂ monolayers, FeP₂ monolayers are cheaper, safer, and more environmentally friendly. In addition, FeP₂ and MoS₂ monolayers have some similar properties in the air, such as good oxidation resistance. FeP₂ monolayers have better optical

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properties and are more suitable as anode materials for KIBs, so they can be used to replace MoS₂ monolayers in optical and KIBs applications. In this work, the structural character, chemical stability, and mechanical and electronic properties of FeP₂ monolayers were calculated by density functional theory (DFT). The optical properties of FeP₂ monolayers were calculated and compared with MoS₂ monolayers. Besides, our computations demonstrated that the FeP₂ monolayer possessed low diffusion barriers and a high capacity as an anode material for KIBs. The discovery of these special properties can make FeP₂ monolayers have great application prospects as photoelectric materials and anode materials for KIBs.

Computational method

DFT calculations were carried out in the Vienna *Ab initio* Simulations Package (VASP),^{47–50} with the projector-augmented wave (PAW) method used to deal with the interaction between electrons and ions.⁵¹ The exchange–correlation functional was treated through the generalized gradient approximation (GGA)⁵² in the form of Perdew–Burke–Ernzerhof (PBE).⁵³ The energy and the force standard received on each atom were set to 10^{−6} eV and 0.01 eV Å^{−1}, respectively. The energy cutoff of the plane wave was set to 400 eV, and a 13 × 13 × 1 Monkhorst–Pack⁵⁴ *k*-grid for Brillouin zone sampling was used for the geometry optimization and self-consistent calculations. To avoid the influence between adjacent layers, the FeP₂ monolayer was placed on the *xy* plane with the *z* direction perpendicular to the layer plane, and a vacuum space of 30 Å was used in the *z* direction.

The calculation of the phonon spectra was completed in the PHONOPY program.⁵⁵ Also, the phonon spectrum of a 2 × 2 × 1 supercell was calculated. In the *ab initio* molecular dynamics (AIMD) simulation, the *NVT* canonical ensemble was adopted, and 6 × 6 × 1 supercells were considered. The simulation lasted for 5.0 ps with a time step of 1.0 fs, and the temperature was controlled by using the Nosé–Hoover method.⁵⁶ Because PBE tended to underestimate the energy band gap, we used the HSE06⁵⁷ hybrid function to calculate a more accurate electronic band structure and optical properties.

Chemical bonding analysis of the FeP₂ monolayer was performed using the solid-state adaptive natural density partitioning (SSAdNDP) method,⁵⁸ which was developed by Boldyrev *et al.*^{59–62} We chose the def2-TZVP⁶³ basis set as the plane-wave projection of the electron density matrix. The climbing-image nudged elastic band (CI-NEB) method⁶⁴ was employed to study the adsorption kinetics of O₂ molecules. To this end, a 4 × 4 × 1 supercell was established, which contained 16 Fe atoms and 32 P atoms. Nine images were used to calculate the reaction path. The long-range van der Waals (vdW) interaction between O₂ molecule and FeP₂ monolayer was considered by the DFT-D3 method.⁶⁵ Similarly, when the FeP₂ monolayer was assessed as the anode material for KIBs, the CI-NEB method was used to explore the lowest energy barriers and diffusion path of K atoms on the FeP₂ monolayer, and the vdW interactions were

considered by the semiempirical DFT-D2 method.⁶⁶ This method has been proved to be a reliable K content adsorption method for the efficient identification of graphene-based materials.³³ Each intermediate image of the CI-NEB simulation was relaxed until the perpendicular force was less than 0.02 eV Å^{−1}. All the crystal structures were visualized using the VESTA software package.⁶⁷

Results and discussion

Fig. 1(a) shows the monolayer structure of FeP₂, in which one unit cell of an FeP₂ monolayer consists of one Fe atom and two P atoms. Like the structure of MoS₂, a Fe atom is sandwiched between two P atoms. The optimized lattice parameters of the FeP₂ monolayer were found to be $a = b = 2.78$ Å, the thickness was 3.27 Å, and the Fe–P bond length was 2.29 Å. To evaluate the energetic stability of the FeP₂ monolayer, we calculated the formation energy ΔH , defined as

$$\Delta H = \frac{E_{\text{total}} - n_1 \times E_{\text{Fe}} - n_2 \times E_{\text{P}}}{n} \quad (1)$$

where E_{total} is the total energy of FeP₂, and E_{Fe} and E_{P} are the energies per atom of the face-centered cubic (fcc) Fe and triclinic P₂₄ solids, respectively. The factors n_1 and n_2 are the atomic numbers of Fe and P, while the factor n is the total atomic number in the unit cell. The calculated ΔH was negative (−0.11 eV per atom), indicating that the formation of the substance was exothermic and could exist stably. We calculated the phonon spectrum to assess its dynamic stability. As shown in Fig. 1(b), the fact that it had no imaginary phonon mode in the whole Brillouin zone confirmed that our predicted FeP₂ was dynamically stable. To evaluate its thermal stability, we performed AIMD simulation at 300, 400, and 500 K. It can be seen in Fig. 1(c) that the framework of the FeP₂ monolayer remained intact without disruption at the temperature of 300 K, which showed its thermal stability. We further simulated AIMD at 400 and 500 K, as shown in Fig. S5 (ESI[†]), indicating that the FeP₂ monolayer could also be stable at 400 K. However, at the temperature of 500 K, the structure was disrupted, which showed that its melting point was between 400 and 500 K.

By calculating the elastic constants of its materials, its mechanical properties were studied. The calculated elastic constants, Young's modulus, and Poisson's ratio are shown in Table 1.

For mechanically stable 2D materials, the elastic constants need to satisfy $C_{11}C_{22} - C_{12}^2$ and $C_{66} > 0$.^{68,69} Obviously, the calculated elastic constants satisfied this condition, indicating its mechanical stability. Young's modulus is a physical quantity that describes the ability of a material to resist deformation, and it reflects the flexibility or rigidity of materials. The Young's modulus of a flexible material is lower. It can be seen that the Young's modulus of 2D FeP₂ was 69.53 N m^{−1}, which is lower than most of the 2D materials reported so far, such as graphene (344 N m^{−1}),⁷⁰ MoS₂ (123 N m^{−1}),⁷¹ and 2D phosphoborane (142.5 N m^{−1}),⁶² but in the same order of magnitude as silicene (65 N m^{−1}).⁷² This shows that the FeP₂ monolayer deforms

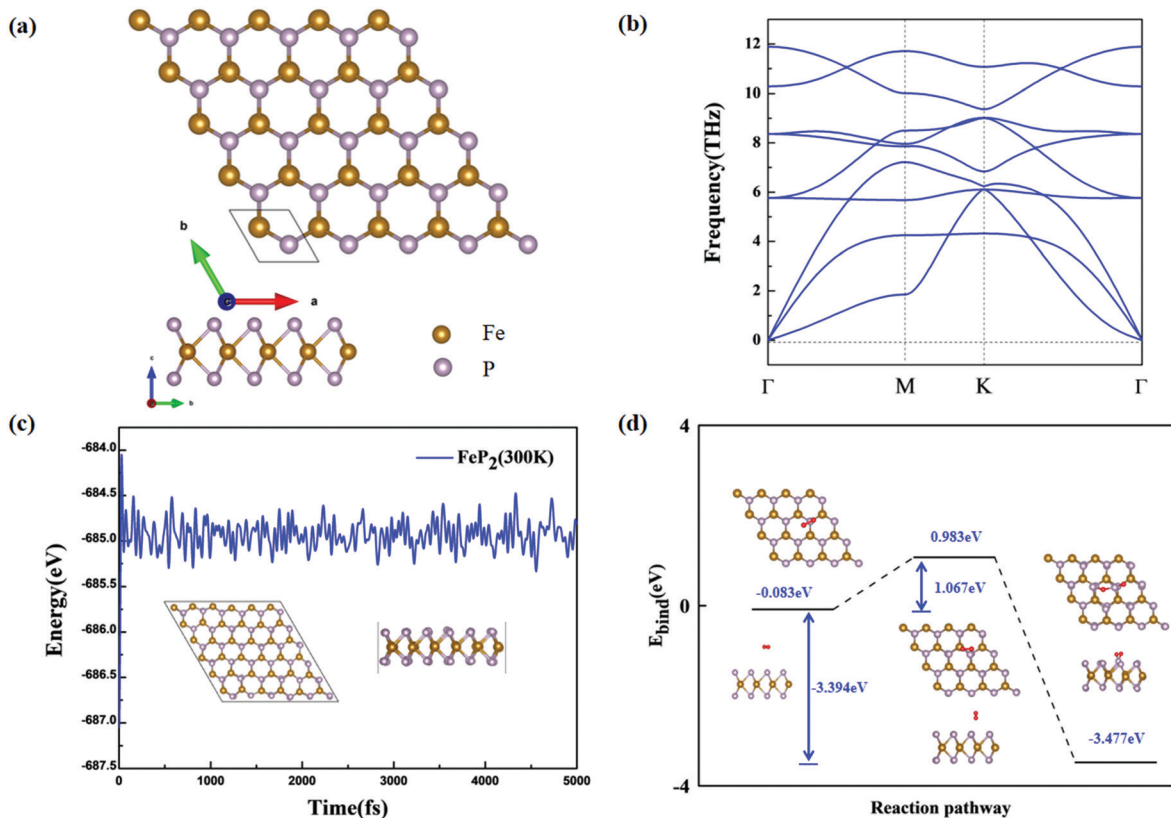


Fig. 1 (a) Top and side views of the optimized geometric structures of the FeP₂ monolayer. (b) Phonon spectra of the FeP₂ monolayer. (c) AIMD simulation of the FeP₂ monolayer at 300 K, with a variation of the energy fluctuation with time step, and a snapshot of the FeP₂ monolayer. (d) The reaction pathway and energy barrier from physisorption to chemisorption of an O₂ molecule on the FeP₂ monolayer.

Table 1 Calculated elastic constants (C_{ij} , N m⁻¹), Young's modulus (E_{2D} , N m⁻¹), and Poisson's ratio (ν) of the FeP₂ monolayer

Structure	C_{11}/C_{22}	C_{12}	C_{66}	E_{2D}	ν
FeP ₂	78.25	26.12	26.07	69.53	0.33

greatly under external stresses. Therefore, the FeP₂ monolayer has a strong sensitivity to its elastic deformation and has favorable mechanical flexibility. Like MoS₂ monolayers, the FeP₂ monolayer is a soft material that is expected to be used in flexible batteries and electronic devices. The Poisson's ratio of the FeP₂ monolayer was calculated to be 0.33, which is within the reasonable range of 2D materials (0–0.5). The spin-polarized calculation confirmed that the FeP₂ monolayer was in a diamagnetic ground state, indicating that there were no unpaired electrons or dangling bonds.

As is well known, phosphorene has excellent properties, but it is easy to be oxidized in air, which greatly restricts its applications.⁷³ Therefore, it is vital to consider the oxidation resistance of the FeP₂ monolayer. The energy barrier from physisorption to chemisorption of an O₂ molecule on the FeP₂ monolayer surface was investigated by the CI-NEB method. The binding energy of the monolayer and O₂ interaction is defined as

$$E_{\text{bind}} = E_{\text{total}} - E_{\text{FeP}_2} - E_{\text{O}_2} \quad (2)$$

where E_{total} , E_{FeP_2} , and E_{O_2} are the energies of the FeP₂ monolayer adsorbed by an O₂ molecule, the FeP₂ monolayer, and a single O₂ molecule in the triplet spin state, respectively. By definition, the more negative the E_{bind} , the stronger the adsorption. Fig. S1 (ESI[†]) shows the physical adsorption of O₂ molecules at several different positions on the FeP₂ monolayer. We choose the structure with the lowest E_{bind} (−0.083 eV) to simulate the oxidation process.

As shown in Fig. 1(d), in the stage of physisorption, the O₂ molecule was located 3.6 Å above the surface of the FeP₂ monolayer, the O–O bond length was 1.23 Å, and the binding energy was −0.083 eV. In the transition state, the O₂ molecule was located 2.24 Å above the surface of the FeP₂ monolayer, and the O–O bond length was elongated to 1.27 Å. The transition from physisorption to chemisorption required the O₂ molecule to overcome an activation energy of 1.067 eV. The calculated activation energy was much higher than that of phosphorene (0.700 eV).⁷⁴ It is equivalent to PC₆ (1.080 eV)⁷⁵ under air stability, indicating that FeP₂ might be chemically stable in air. To further confirm this result, we carried out AIMD simulations of FeP₂ and O₂ molecules at 300 K, using a 6 × 6 × 1 supercell. As shown in Fig. S2 (ESI[†]), the O₂ molecules move away from the FeP₂ monolayer, rather than dissociate

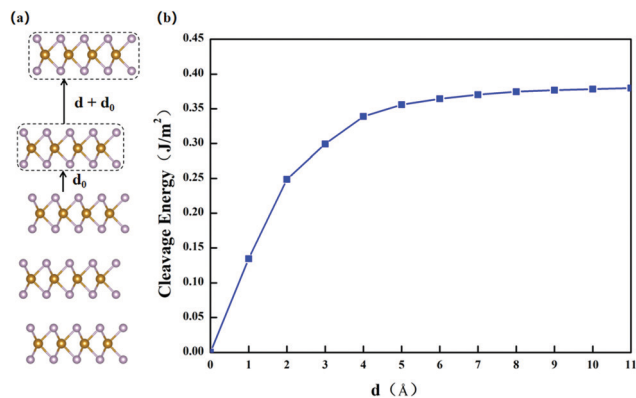


Fig. 2 (a) Separating a monolayer from its neighboring four layers. (b) Cleavage energy as a function of the separation distance for a fracture in the FeP₂ bulk.

into oxygen atoms after 5 ps. As a result, the FeP₂ monolayer exhibited good chemical inertness in air.

To obtain the possibility of FeP₂ monolayers, a mechanical exfoliation strategy was used. The cleavage energy E_{cl} for separating a FeP₂ monolayer from a neighboring four layers was calculated. E_{cl} is defined as the minimum energy required during the exfoliation process. We first established a five-layer slab, in which four layers were fixed and the top monolayer was flexible, as shown in Fig. 2. The cleavage energy was calculated by increasing the separation distance d . Finally, the distance d_0 between layers was calculated to be 3.50 Å . With the increase in d , the cleavage energy gradually converged to a constant value of $\sim 0.38 \text{ J m}^{-2}$. Notably, the calculated cleavage energy was equivalent to that of graphene (0.37 J m^{-2})⁷⁶ and MoS₂ (0.30 J m^{-2})⁷⁷, indicating a high possibility of separating FeP₂ monolayers in experiments.

The band structure and projected density of states (PDOS) of the FeP₂ monolayer were computed using the HSE06 functional, as shown in Fig. 3. The valence band maximum (VBM) of the structure was located at the M point, and the conduction band minimum (CBM) was located at the K point, which indicates that the FeP₂ monolayer was an indirect semiconductor with a band gap of 0.68 eV. Through PDOS analysis, VBM

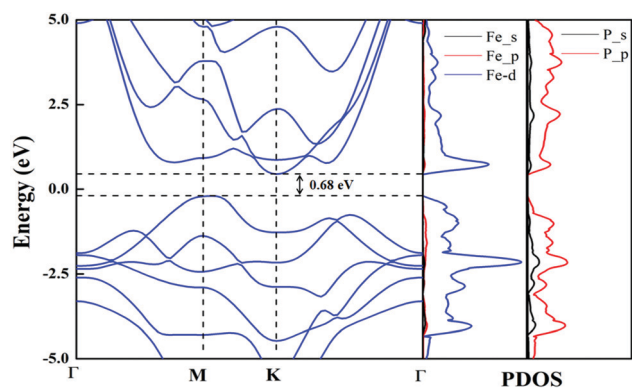


Fig. 3 Electronic band structure and PDOS of the FeP₂ monolayer at the HSE06 level.

and CBM were found to be mainly contributed to by the Fe-d orbital and the P-p orbital.

The interpretation of the FeP₂ monolayer bonding picture is an important step in understanding the nature of this unique and multifunctional material. To deeply understand the bonding nature and stabilizing mechanism of the FeP₂ monolayer, we calculated the electron localization function (ELF). Generally, the values 1.00 and 0.50 correspond to a fully localized localization of electrons and fully delocalized electrons, respectively, while a value near 0.00 implies an area with low electron density. To highlight the multicenter bonds in the hexagonal rings, we drew ELF maps at the different highest points. As shown in Fig. 4, there was a triangle-like area of electron localization probability inside the rings, indicating the existence of multicenter bonds in the rings.

We used the SSAdNDP method to further examine the chemical bonding pattern of the FeP₂ monolayer ($4 \times 4 \times 1$ supercell), as visualized in Fig. 5. This showed that every phosphorus had one lone pair ($1c-2e$) with occupation numbers (ONs) of 1.81 $|e|$. Every Fe atom was bonded to six neighboring P atoms by two-center-two-electron ($2c-2e$) bonds with ONs = 1.85 $|e|$. After localization of all the lone pairs on P and $2c-2e$ bonds, 32 out of 288 valence electrons remained unlocalized in our supercell. We tested $1c-2e$ bonds on Fe atoms, but found that the occupation numbers were about 0.5–0.6 $|e|$. Therefore, there may be multicenter bonds present. After that, the bonding of three Fe atoms in hexagonal rings was tested, and $3c-2e$ multicenter bonds were found. The occupation number was 1.45 $|e|$. As this numerical value was not very large, we continued to look for multicenter bonds of more atoms. Hence, we found that three Fe and six P atoms formed $9c-2e$ bonds with ONs = 1.93 $|e|$, and the occupation numbers of 1.93 $|e|$ mainly came from Fe atoms. Therefore, the abundance of multicenter bonds led to robust connections between the Fe and P atoms, thus, enhancing the stability of the structure.

Recent studies have shown that 2D materials with narrow band gaps can serve as good infrared photodetectors and solar energy harvesters.^{78,79} Thus, the absorption coefficient was calculated by the HSE06 functional to further explore the optical properties of the FeP₂ monolayer. The FeP₂ monolayer has no anisotropy in the x - and y -directions, so we only

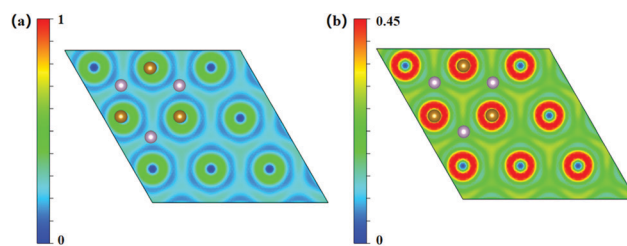


Fig. 4 ELF slice with 001 Miller indices. (a) The color of red and blue refer to the highest (1.00) and the lowest value (0.00) of ELF. (b) The color of red and blue refer to the highest (0.45) and the lowest value (0.00) of ELF. The isosurface value is 0.54. Brown and white balls represent Fe and P atoms, respectively.

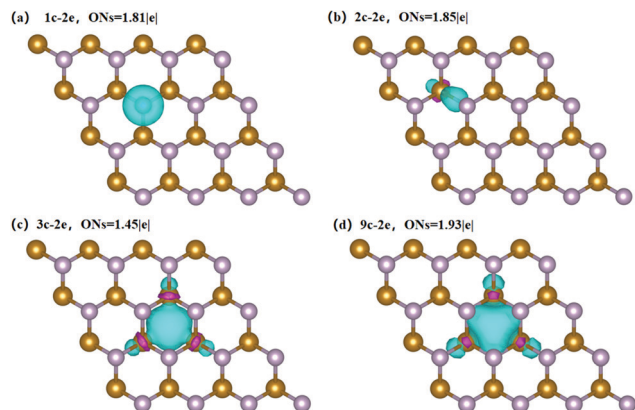


Fig. 5 Schematic of SSAdNDP chemical bonding patterns for the FeP_2 monolayer. The isosurface value was 0.06.

analyzed the optical properties in the x -direction, which is similar to 2D MoS_2 . As shown in Fig. 6(a), the area within the dotted line is the visible light range. It can be seen that the FeP_2 monolayer not only exhibited good optical absorption in the visible and ultraviolet regions, but also had large absorption in the infrared region. In contrast, the MoS_2 monolayer only had significant light absorption in the ultraviolet and visible regions. It is well known that 43% of the solar energy is in the infrared region and that the MoS_2 monolayer is an excellent sunlight absorber. Therefore, the FeP_2 monolayer may be a better solar absorber than the MoS_2 monolayer and can also be used as an infrared photodetector. These results indicate that the FeP_2 monolayer will be a very promising material for future optoelectronic devices.

The FeP_2 monolayer is a narrow band gap semiconductor that can form a metallic state when absorbing metal ions, thus promoting electrical conductivity. Consequently, we then investigated the adsorption and diffusion behavior of the isolated K atom on the surface of the FeP_2 monolayer. A $4 \times 4 \times 1$ supercell was adopted to find the most stable adsorption site

for K. According to the symmetry of the FeP_2 monolayer, we considered five possible adsorption sites, which are shown in Fig. 6(b). The adsorption energy (E_{ad}) is evaluated using

$$E_{\text{ad}} = E_{\text{K+FeP}_2} - E_{\text{FeP}_2} - E_{\text{K}} \quad (3)$$

where $E_{\text{K+FeP}_2}$, E_{FeP_2} and E_{K} are the total energies of K-adsorbed, pure FeP_2 monolayers and the energy per atom in bulk K, respectively. By definition, more negative adsorption energy indicates more stable adsorption of K on the FeP_2 monolayer.

The A_1 and A_2 adsorption sites are located directly above the Fe and S atoms, respectively. The A_3 is located in the center of the hexagon composed of Fe and P atoms, the A_4 site represents the center of two adjacent Fe atoms, and the A_5 site denotes the center of Fe and P atoms. After structural relaxation, there were only three inequivalent stable adsorption sites. The adsorption sites of A_4 and A_5 were unstable and the K atom transformed to the A_1 site. The adsorption energy is shown in Table S1 (ESI[†]). Among the three stable adsorption sites, the A_1 site was the most favorable with an adsorption energy of -1.78 eV.

We calculated the charge density difference to examine the adsorption interaction of the K atom and FeP_2 monolayer, as indicated in Fig. 6(c). The yellow and blue regions represent the accumulation and the decreasing trend of charge, respectively.

It can be clearly seen that the charge accumulated on the FeP_2 monolayer and the charge depletion occurred around the K atom, indicating that electrons were transferred from the K atom to the FeP_2 monolayer during the adsorption of the K atom. Further Bader charge analysis showed that $0.76 |e|$ was transferred from the K atom to the FeP_2 monolayer. Additionally, the band structure of K atom intercalated FeP_2 monolayer is illustrated in Fig. S3 (ESI[†]). We found that the FeP_2 monolayer turned into a metallic state after adsorption of the K atom, ensuring good electrical conductivity during the battery cycle.

On the other hand, the diffusion energy barrier of K on the FeP_2 surface is closely related to the charge/discharge rate of the battery. Hence, the CI-NEB method was used to estimate the diffusion barriers. Considering the stable adsorption sites of A_1 , A_2 , and A_3 , and the K atoms preferring to occupy the A_1

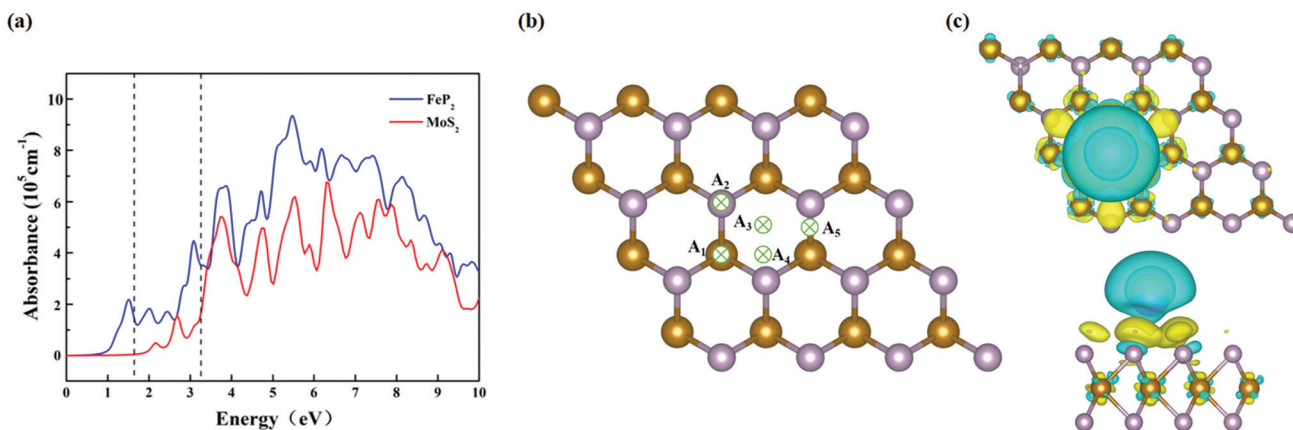


Fig. 6 (a) Light absorption spectra of FeP_2 and MoS_2 monolayers calculated by the HSE06 method. (b) Different adsorption sites of K ions on the surface of the FeP_2 monolayer. (c) Charge density difference of K ions on the FeP_2 monolayer.

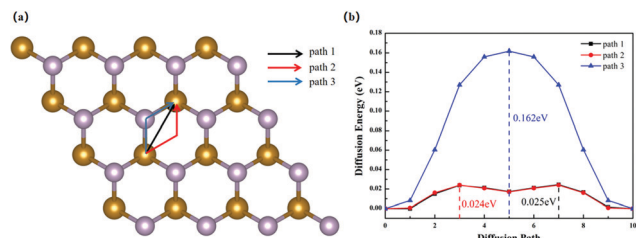


Fig. 7 (a) The migration paths of K diffusion on the FeP₂ monolayer. (b) The diffusion barrier profiles for K migration for the considered three paths.

site, there were three possible diffusion pathways, as shown in Fig. 7(a). For path I, the K ion migrates directly from the A₁ site to the adjacent A₁ site, and the resulting diffusion energy barrier is 0.025 eV. For path II, the K ion moves from the A₁ site to the A₃ site, and then to another the A₁ site, with a diffusion energy barrier of 0.024 eV. For path III, the K ion moves from the A₁ site to the A₂ site, and then to another A₁ site, with a diffusion energy barrier of 0.162 eV, as shown in Fig. 7(b). The diffusion energy barrier of path II was the lowest, only 0.024 eV. It was also significantly lower than the commercial graphite anode from LIBs (0.400 eV)^{80,81} and even lower than the diffusion energy barrier of MoS₂ (0.063 eV)³³ as an anode material.

The storage capacity of K atoms is an important property of the battery, which is directly proportional to the number of adsorbed K atoms on the surface. Therefore, to explore the capacity, different contents of K ($x = 0.125, 0.500, 1.000, 1.500$) were added to both sides of the FeP₂ monolayer, and the average adsorption energy was calculated to examine the adsorption stability, which is defined as

$$E_{\text{ave}} = \frac{E_{\text{K+FeP}_2} - E_{\text{FeP}_2} - nE_{\text{K}}}{n} \quad (4)$$

where n is the number of adsorbed K atoms, $E_{\text{K+FeP}_2}$ and E_{FeP_2} are the total energies of the K-adsorbed and pure FeP₂ monolayers, respectively. Similarly, as long as E_{ave} is negative, the K atoms can be adsorbed stably.

Since the adsorption energy of the A₁ site was the largest, and adsorption on both sides can reduce the Coulomb repulsion between K ions, the adsorption sites on both sides of A₁

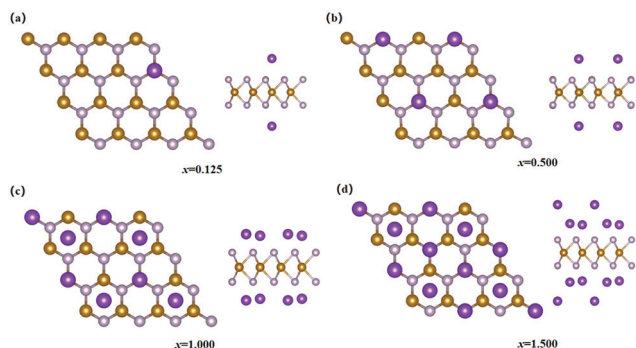


Fig. 8 Structures of the K adsorption models on different concentrations of FeP₂, including $x =$ (a) 0.125, (b) 0.500, (c) 1.000, and (d) 1.500.

were first adopted. As clearly shown in Fig. 8, when the K content was 0.125 and 0.500, E_{ave} was -1.730 and -1.070 eV, respectively. The distance between K ions was too close, which led to Coulombic repulsion when the K content was at $x = 1.000$. The K ions were displaced from the A₁ sites on both sides of the FeP₂ monolayer, so we considered A₂ sites with slightly weaker adsorption energy, and E_{ave} was -0.835 eV. At the same time, we considered the adsorption of K at the A₁ site on the same side. Although there was no displacement, the calculated average adsorption energy was 0.076 eV, which is obviously unstable. At $x = 1.500$, we also considered that all K ions were adsorbed on both sides of the A₁ and A₂ sites, and the K ions were displaced. To reduce the Coulombic repulsion between K ions, they were adsorbed on both sides of A₁, A₂, and A₃ sites, and E_{ave} was -0.56 eV. To sum up, the adsorption of K contents at $x = 0.125, 0.500, 1.000$, and 1.500 on the FeP₂ monolayer is favorable and the structure energy is stable. At $x = 2.000$, due to the large number and radius of K ions, they could not be adsorbed stably on the A₁, A₂, and A₃ sites of the FeP₂ monolayer at the same time. Accordingly, the maximum content of K that could be adsorbed on the FeP₂ monolayer was 1.500.

We calculated the storage capacity of K ions by the formula $C = xF/M$. In this formulation, M , F , and x define the molecular mass of FeP₂, the Faraday constant ($28601 \text{ mA h mol}^{-1}$), and the concentration of the adsorbed K ions ($x = 1.500$ in this work) per unit FeP₂. The calculated maximum storage capacity of the FeP₂ monolayer was $456.84 \text{ mA h g}^{-1}$, which was larger than those of graphite (273 mA h g^{-1})⁴⁶ and MoS₂ monolayers ($334.86 \text{ mA h g}^{-1}$)³³ as an anode material for KIBs. Finally, we investigated the open-circuit voltage (OCV) of the FeP₂ monolayer. The OCV during charging/discharging can be obtained by the following reaction: $\text{FeP}_2 + x\text{K}^+ + x\text{e}^- \leftrightarrow \text{FeP}_2\text{K}_x$. Thus, ignoring the contribution of volume and entropy,⁸² the average OCV can be evaluated by⁸³

$$\text{OCV} = \frac{E_{\text{FeP}_2} + mE_{\text{K}} - E_{\text{mK+FeP}_2}}{me} \quad (5)$$

where m is the concentration of the adsorbed K atoms. It was clearly found that as the K concentration increased, the OCV dropped from 1.725, 1.069, 0.835, to 0.557 V, as shown in Fig. S4 (ESI[†]). This shows that there was a steady voltage change during cycling. The OCV at the final stage was as low as 0.557 V, which is within the working voltage range (01.0 V) of anode materials.^{84,85} Based on these results, FeP₂ monolayers are a promising candidate anode material for KIBs.

Conclusions

In summary, we successfully predicted an FeP₂ monolayer that is isoelectronic with MoS₂. By means of DFT investigation, the FeP₂ monolayer demonstrated good dynamic, mechanical, and thermal stabilities. The low cleavage energy indicates that it is feasible to exfoliate monolayers from the bulk structure. We also verified that the FeP₂ monolayer can resist oxidation in air. The electron properties calculated by the HSE06 method

showed that the FeP₂ monolayer is a semiconductor with an indirect band gap of 0.68 eV, and has light absorption in the infrared, visible, and ultraviolet regions. Chemical bonding analysis showed that there are 9c–2e bonds in every hexagonal ring of the FeP₂ monolayer. The storage capacity of the FeP₂ monolayer as an anode material of KIBs reached 456.84 mA h g⁻¹. Moreover, the diffusion barrier was as low as 0.024 eV and had a low OCV. All the calculation results show that the FeP₂ monolayer has potential application prospects in electronic and optoelectronic devices, and as an anode material for KIBs. Moreover, because of its low cost, high safety, and excellent optical properties, the FeP₂ monolayer is expected to replace the MoS₂ monolayer in the fields of solar absorption devices and anode materials for KIBs.

Conflicts of interest

There are no conflicts of interest to declare.

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Notes and references

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